## **Special Issue**

# Model Learning Predictive Control for Industrial Processes

## Message from the Guest Editors

In this Special Issue, we cordially invite your contributions that will feature the latest developments in model-predictive control with regard to bringing a high level of autonomy in the technology but also controlling approaches that combine learning methods using data. Contributions that show applications on pilot plants or actual chemical processes are particularly welcome.

#### **Guest Editors**

Dr. Leyla Özkan

Control Systems Group, Department of Electrical Engineering, De Zaale, 5612 AJ Eindhoven, The Netherlands

Dr. Aleiandro Marquez Ruiz

Control Systems Group, Department of Electrical Engineering, De Zaale, 5612 AJ Eindhoven, The Netherlands

## Deadline for manuscript submissions

closed (15 February 2022)



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Processes
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34

mdpi.com/journal/processes

processes@mdpi.com





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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

#### Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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